

The 9th International Symposium on Advanced Optical Manufacturing and Testing Technologies

26-29 June 2018

Century City International Convention Centre ChengDu, China

Sponsored by:

COS - The Chinese Optical Society

IOE - Institute of Optics and Electronics,

- Chinese Academy of Sciences

SPIE - The International Society for Optics and Photonics

- (Technical Co-Sponsor)

Supported by:

Ministry of Science and Technology of China

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Conferences:

- 1 Large Mirror and Telescopes
- 2 Advanced Optical Manufacturing Technologies
- 3 Optical Test and Measurement Technology and Equipments
- 4 Micro/Nano Optics and Subwavelength Electromagnetics
- 5 Meta Surface-wave and Surface Plasmon Lithography
- **6** Extreme Manufacturing Technology
- 7 Innovative Manufacturing Technology
- 8 Flexible Materials and Devices
- 9 Optoelectronic Materials and Devices for Sensing and Imaging



Catalogue

Organizations & Committees	3 -
Daily Event Schedule	12 -
Plenary Presentation	15 -
Conferences and Chairs	22 -
Conference 1: Large Mirror and Telescopes	22 -
Conference 2: Advanced Optical Manufacturing Technologies	25 -
Conference 3: Optical Test, Measurement Technology and Equipments	31 -
Conference 4: Micro/Nano Optics and Subwavelength Electromagnetics	37 -
Conference 6: Extreme Manufacturing Technology	38 -
Conference 5: Meta Surface-wave and Surface Plasmon Lithography	45 -
Conference 7: Innovative Manufacturing Technology	50 -
Conference 8: Flexible Materials and Devices	52 -
Conference 9:Optoelectronic Materials and Devices for Sensing and Imaging	55 -



Organizations & Committees

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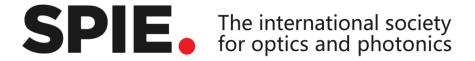
COS - The Chinese Optical Society



IOE - Institute of Optics and Electronics, Chinese Academy of Sciences



SPIE - The International Society for Optics and Photonics (*Technical Co-Sponsor*)



Supported by:

- Ministry of Science and Technology of China
- Chinese Academy of Sciences (CAS)
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Symposium General Chair:

Bingkun ZHOU, Academician, Chinese Academy of Sciences; Former President of COS

Guangcan GUO, Academician, Chinese Academy of Sciences; Former President of COS

Liwei ZHOU, Academician, Chinese Academy of Engineering; Beijing Institute of Technology

Qihuang GONG, Academician, Chinese Academy of Sciences; President of COS; Peking University

Henri LEZEC, National Institute of Standards and Technology

Minghui HONG, National University of Singapore

Yuwen QIN, National Natural Science Foundation of China

Yudong ZHANG, President of Chengdu Branch, Chinese Academy of Sciences, Director of Academic Committee of Institute of Optics and Electronics

Enhai LIU, Vice President of Institute of Optics and Electronics Chinese Academy of Sciences



Organizer:

- Committee of Optical Manufacturing Technology, Chinese Optical Society
- Opto-Electronic Journal
- State Key Laboratory of Optical Technologies on Nano-Fabrication and Micro-Engineering, Institute of Optics and Electronics, Chinese Academy of Sciences
- Key Laboratory of Optical Engineering, Chinese Academy of Sciences
- Key Laboratory of Adaptive Optics, Chinese Academy of Sciences
- Key Laboratory of Optoelectronics Technology on Space Precision Measurement, Institute of Optics and Electronics, Chinese Academy of Sciences
- Key Laboratory of Optoelectronic Technology & Systems (Chongqing University), Ministry of Education, China

Supporting Organization:

TRIOPTICS CHINA



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Rui ZHOU, Xiamen University

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Jinxue WANG, The International Society for Optics and Photonics Xiangang LUO, Institute of Optics and Electronics, Chinese Academy of Sciences



Symposium General Chair:

Bingkun ZHOU, Academician, Chinese Academy of Sciences, Former President of COS

Biography: Bingkun Zhou, a specialist of Laser and Optoelectronics, was born in March, 1936 in Sichuan, China. He graduated from Tsinghua University, Beijing, China in 1956. Since then he has been with the Electronic Engineering Department at the same university. From 1960 to 1962 he was a visiting scholar at Leningrad Electro technical Institute, Leningrad, former USSR. From 1983 to 1984 he was a visiting scholar of Applied Physics Department, Stanford University, U.S.A. From 1985, he has been a professor



of Electronic Engineering Department at Tsinghua University. He was elected Academician of Chinese Academy of Sciences in 1991 and was elected Academician of Third World Academy of Sciences in 2001. At present, he is also the vice-president of the Chinese Optical Society, fellow of the Optical Society of America and Chinese Institute of Electronics.

He has been engaged in laser and optoelectronics research and teaching for more than 40 years. In 1984, he made key contributions to development of diode-pumped, narrow line width and frequency stable Solid State Lasers. He with his research group has made scientific research achievements in the area of "external cavity semiconductor lasers", "semiconductor laser pumped solid state lasers", "crystal fibers and devices", "fiber ring cavity and their applications", "fiber amplifiers and lasers", "high temperature optical fiber thermometer and its applications" and "DWDM optical fiber transmission and all optical network technology". He has won 13 national and ministry-level prizes in China. He is the author or co-authors of about 100 papers, presentations, patents and one book Laser Principle.



Symposium General Chair:

Guangcan GUO, Academician, Chinese Academy of Sciences, Former President of COS

Biography:Guo Guangcan, Member of CAS, Chief Scientist of 973 Project, currently teaching at University of Science and Technology of China, signed with NUPT on October 31st to become an honorary professor withthe university. President Yang Zhenattended the ceremony to present the letter of appointment, after which Professor Guo gave a lecture titled "Quantum High Precision Measurement based on Weak Measurement Theory", and had a follow-up discussion with theaudience.



Guo Guangcan, professor with University of Science and Technology of China, and Director of the Key Lab of CAS Quantum Information, is Chief Scientist in his field in Chinese Academy of Sciences, and Chief Scientist of Quantum Communication and Quantum Communication Technologies.

Professor Guo has long devoted himself to the research on theory and experiment of quantum optics, quantum cryptography, quantum communication, and quantum computation, as well as the teaching of Optics and Physics, and has achieved a series of internationally recognized accomplishments. He has published over 820 journal researches, with SCI10781 citations, including 9788 non-self citations, and 11 book-length researches (translations). He has supervised a total of 40 PHD candidates and 30 Master candidates, 4 of whom have made the Top Hundred PHD Dissertations and 2 recipients of National Outstanding Youth Fund. Professor Guo has been awarded the honor of Progressive Staff of CAS, Moe Outstanding Teachers of China, and was elected Member of CAS in 2003.



Symposium General Chair:

Liwei ZHOU, Academician, Chinese Academy of Engineering

Biography: Liwei ZHOU, Professor, PhD, Member of Chinese Academy of Engineering, was born in Shanghai in 1932. He was graduated from Beijing Institute of Technology (BIT) in 1958 and received the USSR Candidate Degree (PhD) of physics-mathematical science in 1966. In 1984 he was titled "Outstanding Expert at the State Level" for developing a school of his own in the electron optics study, and in the same year he was promoted to the rank of full professor. He used to be



the Chairman of Academic Committee, BIT, the vice president of Chinese Optical Society and Chairman of Association of Science and Technology, BIT. Now he is the Chair-Expert of BIT, Honorary Director of School of Basic Education of BIT and president of Beijing Optical Society.

Prof. Zhou Liwei is engaged in electron optics and photoelectronic imaging. Since 1978, Prof. Zhou Liwei has published 6 monographs and 6 printed teaching materials and more 270 academic and technical papers at home and abroad. His monograph "Electron Optics with Wide Beam Focusing" has been awarded the Chinese Books Prize in 1994, the National Books Prize (nominative prize) in 1995 and the Nation-wide Scientific Excellent Books First Prize in 1995.

Achievements of Prof. Zhou Liwei in scientific research were awarded the National Science Congress Prize in 1978, the Ministry's First and Second Prizes for Science and Technology Progress in 1980, 1990, 1995 and 1996, the Guang Hua Fund First Prize for Science and Technology in 1991. He was also twice of the winner of State Prize for Science and Technology Progressin1991 and 1996. In 1996, he was given a title of "Advanced Worker" by State Personnel Ministry for his outstanding service in educational and scientific field. In 1997, he got an Honorary Degree of Doctor of Science by Samara State Aerospace University, Russia. In 1999, he was elected member of Chinese Academy of Sciences, and in 2000, he was elected Foreign member of Academy of Engineering Sciences of the Russian Federation.



Symposium General Chair:

Qihuang GONG, Academician, Chinese Academy of Sciences, President of COS

Biography: Qihuang Gong received the B.S. and Ph.D. degrees in physics from Peking University, China in 1983 and 1989, respectively. In 1988 and 1989, he studied atomic optics at Manchester University, UK. He is currently a Full Professor and a Cheung Kong Scholar at the Physics Department, Peking University. Moreover, he has been appointed as the Director of both the State Key Laboratory for Artificial Microstructure and Mesoscopic Physics and



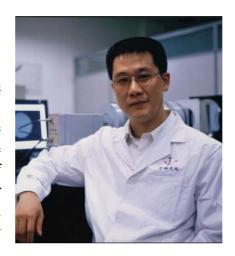
the Institute of Modern Optics, Peking University. His current research interests are in ultrafast optics and spectroscopy, nonlinear optics, and mesoscopic optical devices for applications in optical information processing and communication. Professor Gong has authored more than 200 articles. He also serves as a Topic Editor of Optics Letters, an Advisor Editor of Chemical Physics Letters, an Editorial Board Member of the Journal of Optics, and an Associate Editor-in-Chief at Chinese Physics B, Chinese Optics Letters, Acta Physics Sinica (in Chinese), and Quantum Electronics (in Chinese). He was also elected as an Executive Council Member of Chinese Optics Society and Chinese Physical Society. Moreover, he served as a Member of the International Council of Optical Society of America (OSA), a Fellow of IOP, and a Co-chair of Asian Intense Laser Network.



Symposium General Chair:

Yudong ZHANG, President of Chengdu Branch, Chinese Academy of Sciences (China)

Biography: Yudong ZHANG, PhD and Research Professor, President of Chengdu Branch, CAS (Chinese Academy of Sciences) is a member of the Appraisal Expert Team of Information Directorate of NSFC (National Natural Science Foundation of China), a vice-chair of Bio-optics and Laser Medicine Subcommittee of COS (Chinese Optical Society), a vice-Chair of Electro-Optical Specialty Committee of Chinese Society of Astronautics,



and a committeeman of Quantum Electronics and Electro-Optical Subcommittee of CIE (Chinese Institute of Electronics), an adjunct professor of UESTC (University of Electronic Science and Technology of China) and Zhejiang University respectively.

Mr. Zhang received his BS from Zhejiang University in 1984, his MS from IOE in 1987, and his PhD from Shanghai Institute of Optics and Fine Mechanics, CAS, in 1991. From 1991 to 1997 he held the technical posts of Research Assistant, Research Associate Professor and Research Professor in Fujian Institute of Research on the Structure of Matter, CAS. He has been working in IOE since 1998 and serving as President since 2003.

For more than 10 years, he has carried out many frontier researches in the fields of adaptive optics, microlithography and new materials of non-linear optics and has obtained many innovative achievements that are leading in China or advanced in the world. He has won one first-grade award of CAS Prize for S&T Progress and CAS Prize for Invention respectively. Altogether, he has applied for and obtained 38 pieces of patents, and published more than 50 papers among which 30 are included in EI Database and 10 in SCI Database.

From1998 to present, he has been taking charge of the development of the adaptive optical (AO) system for imaging live human eye retina with high resolution. The system is the first practical compact AO system for this application in the world.

He is also in charge of the development of Dynamic Wavefront Correction AO System for the new generation of ICF prototype system in China. It is the first AO system that can reduce the wavefront distortion of laser beam in ICF system from 9λ to about 1.5λ in China. This extends the application of adaptive optics in the ICF field and is at the advanced world level.



Organization Committee:

Enhai LIU, Vice President of Institute of Optics and Electronics, CAS (China)

Biography: Professor Enhai LIU, Vice President of Institute of Optics and Electronics (IOE) Chinese Academy of Sciences, graduated from Dalian University of Technology in 1987, and received his master degree in University of Electronic Science and Technology of China in 2004. He is a committee member of Chinese Optical Society, Chinese Optical Engineering, and Space Optical Engineering.



Professor LIU engaged in space optical precision

measurement technology, especially in light-weight and compact design of the space system, high-sensitivity, low-noise signal processing, real-time image extraction and recognition, smart visual servo method, high dynamic performance control systems, high-precision imaging testing and calibration technology.

As a project leader, chief designer and engineer, professor LIU completed many important projects from national 863, 973, manned space flight and lunar exploration project. He has published over 20 papers and trained more than 20 doctors and masters.





Daily Event Schedule

	Daily Event Scheaule						
Date	Time	Contents	Place				
Monday June 25, 2018	08:00-21:00	Registration For Domestic Authors	Holiday Inn Chengdu Century City-West Tower				
	After 21:00	Late Attendee Contact Hotel Reception Counter For Help	Holiday Inn Chengdu Century City-West Tower				
	08:30-08:45	Opening Ceremony					
Tuesday	08:45-12:00	Plenary Presentation 1 to 3	Crystal hall, floor 5,Century City International Convention Centre				
June 26, 2018	13:00-16:50	Plenary Presentation 4 to 7					
	19:30	Welcome Dinner	Crystal hall, floor 5,Century City International Convention Centre				
		Conference 1	WuHou hall				
	08:00-18:30	Conference 2	GaoXin hall				
		Conference 3	QingYang hall				
Wednesday		Conference 4	JinJiang hall				
June 27, 2018		Conference 5	ChengHua hall				
		Conference 7	QingBaiJiang hall				
		Conference 8	XinDu hall				
		Conference 2	GaoXin hall				
		Conference 4	JinJiang and WuHou hall				
		Conference 5	ChengHua hall				
	08:00-12:00	Conference 6	JingJiang hall				
		Conference 8	XinDu hall				
Thursday		Conference 9	QingYang hall				
June 28, 2018		Conference 3	JinFuRong hall				
		Conference 4	JinJiang and WuHou hall				
	40.00	Conference 5	ChengHua hall				
	13:00-18:30	Conference 9	QingYang hall				
		Poster Presentations	GaoXin hall, floor 5, Century City International Convention Centre				



Opening Ceremony

08:30-08:45 June 26, 2018

Opening Ceremony

<u>Location: Crystal hall, floor 5, Century City International Convention Centre</u>

Plenary Presentation

08:45-12:00 June 26

Plenaries 1 to 3

Crystal hall, floor 5

Location: Crystal hall, floor 5, Century City International Convention Centre

Plenary Session 1 (Time: 08:45 to 09:35)

1. Nanoscale Additive Manufacturing: Coming of Age Prof. MIN GU (Australia)

Royal Melbourne Institute of Technology University

Tea time and Group Photo (09:35-10:20)

Plenary Session 2 (Time: 10:20 to 11:10)

2. Industry 4.0 – Next generation Ultrafast Laser Systems and Ablation Applications Prof. Reinhart POPRAWE (Germany)

Fraunhofer Institute for Laser Technology

Plenary Session 3 (Time: 11:10 to 12:00)

3. Development of Microsphere Assisted Laser Nano-lithography and Optical Nano-imaging Technologies

Prof. Minghui HONG (Singapore)

National University of Singapore.

Lunch time (12:00-13:00)

13:00-14:40 June 26

Plenaries 4 to 5

Crystal hall, floor 5

Location: Crystal hall, floor 5, Century City International Convention Centre

Plenary Session 4 (Time: 13:00 to 13:50)

4. Some milestones in the design, development and manufacture of freeform optics Prof. William T. PLUMMER (USA)

Massachusetts Institute of Technology





Plenary Session 5 (Time: 13:50 to 14:40)

5. Three Dimensional Photonic Manufacturing: From Architectured Metamaterials to **Freeform Optics Design**

Prof. Nicholas Xuanlai FANG (USA)

Massachusetts Institute of Technology

Tea time (14:40-15:10)

15:10-16:50 June 26

Plenaries 6 to 7 Crystal hall, floor 5

Location: Crystal hall, floor 5, Century City International Convention Centre

Plenary Session 6 (Time: 15:10 to 16:00)

6. Solar Adaptive Optics in IOE

Prof. Changhui RAO (China)

Institute of Optics and Electronics, Chinese Academy of Sciences

Plenary Session 7 (Time: 16:00 to 16:50)

7. The European Southern Observatory Giant Optical telescopes of the present and future

Dr. Adrian RUSSELL (Germany)

European Organisation for Astronomical Research in the Southern Hemisphere

Welcome Dinner

19:30 June 26, 2018

Welcome Dinner

Location: Crystal hall, floor 5, Century City International Convention Centre



Plenary Presentation

08:45-09:35 June 26 Plenary Presentation 1 Crystal hall, floor 5

■ Plenary Presentation 1

Title: Nanoscale Additive Manufacturing: Coming of Age

Speaker: Min GU



Abstract: Additive manufacturing is a process of joining materials to make objects from 3D model data, which is usually achieved by layer upon layer approaches. The utilisation of a laser beam is one of the effective ways to achieve this process. In the case of laser additive manufacturing, the fundamental restriction is the limit of the feature size, which is determined by the so called Abbe's law discovered by a German physicist, Ernst Abbe, in 1873. Abbe's barrier means that the size of the features generated by a laser beam is approximately 300 nm, for example, in a visible beam. In this presentation, I will show how

Abbe's limit can be broken in the recent development of optical beam nanolithography. Therefore, the feature size by a laser beam focused by a high numerical lens can be remarkably reduced to 9 nm in a polymerisable material. This breakthrough in laser additive manufacturing will not only provide means that the capacity of an optical disk can be as high as Petabytes, which will allow for the accelerating development of green optical data centres, but also facilitate a new horizon of ultrahigh energy density super-capacitors, nanoscale organic optoelectronic devices, nanoscale chemical reaction chips, artificial neural networks, and biomimetic systems.

Biography:Professor Gu is Distinguished Professor and Associate Deputy Vice-Chancellor at RMIT University and was a Laureate Fellow of the Australian Research Council. He is an author of four standard reference books and has over 450 publications in nano/biophotonics. He is an elected Fellow of the Australian Academy of Science as well as the Australian Academy of Technological Sciences and Engineering. He is also an elected fellow of the AIP, the OSA, the SPIE, the InstP, and the IEEE. He was President of the International Society of Optics within Life Sciences, Vice President of the Board of the International Commission for Optics (ICO) (Chair of the ICO Prize Committee) and a Director of the Board of the Optical Society of America (Chair of the International Council). He was awarded the Einstein Professorship (Chinese Academy of Science, 2010), the W. H. (Beattie) Steel Medal of the Australian Optical Society (2011), the Ian Wark Medal and Lecture of the Australian Academy of Science (2014), the Boas Medal of the AIP (2015) and the Victoria Prize for Science and Innovation (2016). Professor Gu was elected as a Foreign Fellow of the Chinese Academy of Engineering in 2017.



10:20-11:10 June 26 Plenary Presentation 2 Crystal hall, floor 5

■ Plenary Presentation 2

Title: Industry 4.0 – Next generation ultrafast laser systems and ablation applications

Speaker: Reinhart POPRAWE



Abstract: The context of future Laser Applications in modern manufacturing can be summarized by "Digital Photonic Production". The vision of designing a structure or product in the computer and creating it additively or by ablation with high power ultrafast lasers drives many research topics in this area. But also the integration into production chains with the challenge of meeting the demands of production along the lines of Industry 4.0 is starting to be addressed seriously. From the point of Laser technology, main fields of activity are measurement processes of quality relevant data on-line, process control mechanisms and the combination with automation as a whole. A huge challenge is the data

handling and control system technology, which up to now is fragmented and component specific. The need of more integrated data control systems becomes obvious.

Of course, the processes themselves are under intense investigation, such as Laser Ultrafast Ablation and Laser Drilling. Removal rates are the prime goal under economical aspects. New concept and performance results under this aspect will be presented. Also correspondingly increased quality of the resulting products in terms of surface roughness and precision is a key issue of consideration. At ILT the strategy is the continuous improvement of average power of ps- and fs-Laser sources. The present world record in sub ps-pulse durations is 1.5 kW demonstrated in Aachen.

Biography: Reinhart Poprawe has worked in the laser industry and its related organizations for over 30 years. He received an M.A. in physics from California State University in Fresno in 1977. After completion of his Ph.D. in physics (Darmstadt, 1984) he joined the Fraunhofer Institute for Laser Technology (ILT) in Aachen, Germany where he worked as head of a department for laser-oriented process development. Prof. Poprawe started Thyssen Laser Technik GMBH in 1988 and was the company's CEO. Since 1996, he has been managing director of Fraunhofer ILT and holds the University Chair for Laser Technology at the RWTH Aachen. In 2004 he served as vice rector of Aachen University and currently is a member of several boards in the scientific and industrial organizations, e.g. the AKL Arbeitskreis Lasertechnik e. V. Aachen. He also chairs the RWTH International Board and is the Rectors delegate for China.



11:10-12:00 June 26 Plenary Presentation 3 Crystal hall, floor 5

■ Plenary Presentation 3

Title: Development of Microsphere Assisted Laser Nano-lithography and Optical Nano-imaging Technologies

Speaker: Minghui HONG



Abstract: Pushing the optical resolution beyond 100 nm is a key task for laseradvanced manufacturing and light-based surface imaging. Microsphere possesses its versatile capability to enable our current laser precision engineering and optical microscopy down to nanometers scale. In this talk, I will report our research progresses on laser surface nano-patterning and optical nano-imagingvia microsphere. By fine tuning laser processing parameters, feature sizes down to 20 nm areachieved. To enhance laser nano-patterning speed, fs laser micro-lens array (MLA) lithography is developed to achieve parallel, maskless and non-contact surface patterningto push current laser precision

engineering resolution down to sub-100 nm over a large area (cm scale) at a high speed (millions of micro-devices to be created in a few minutes). Meanwhile, we can also insert a microsphere between sample surface and objective lens to enhance optical imaging resolution in both contact and non-contact modes. Feature sizes down to 25nm are observed successfully. By microsphere engineering, fs laser illumination and multiplemicrospheres design, this optical microscope nanoscope would be able to process and image much smaller feature sizes in ambient environment.

Biography:Prof. Hong Minghui specializes in optical engineering. He is invited to serve as an Editor of *Light: Science and Applications*, Associate Editor of *Science China G*, Editor of *Laser Micro/nanoengineering*, and Executive Editor-in-chief of *Opto-Electronic Advances*. Prof. Hong is Fellow of Academy of Engineering, Singapore (FSEng), Fellow of *Optical Society of America (OSA)*, Fellowof *International Society for Optics and Photonics (SPIE)*, Fellow of *International Academy of Photonics and Laser Engineering (IAPLE)* and Fellow of *Institute of Engineers, Singapore (IES)*. Prof. Hong is currently a Full Professor and the Director of Optical Science and Engineering Centre (OSEC), Department of Electrical and Computer Engineering, National University of Singapore. He is also the Chairman of an NUS spin-off company *Phaos Technology Pte. Ltd.*



13:00-13:50 June 26 Plenary Presentation 4 Crystal hall, floor 5

■ Plenary Presentation 4

Title: Some milestones in the design, development and manufacture of freeform optics

Speaker: William T. PLUMMER



Abstract: Freeform optics are lenses or mirrors with surfaces having no rotational symmetry. They were conceived more than a century ago, but have recently received new attention for solving design problems. The special methods needed to manufacture them have included direct cam driven or digital grinding or milling, hot glass sagging, casting, injection molding, and fast-tool diamond turning. More recently, precision 3D printing and nano-crystalline powder compression molding have offered promising new capabilities for inexpensive high-volume commercial production in the

future. Applications of freeform optics have included progressive spectacle lenses, focus adjusting devices, and aperture phase masks for special purposes. These design applications and manufacturing capabilities have been related to each other in interesting ways, and will be illustrated through a selection of patents and photographs of commercial products.

Biography: William Plummer received his PhD in physics from Johns Hopkins. He has taught optics at Hopkins, the University of Massachusetts, and Tufts, is a Senior Lecturer at MIT, and has 102 US patents. During three decades at Polaroid he was Senior Director for optical engineering. He has awards from the OSA, is an elected member of the National Academy of Engineering, and is an Advisory Board member at BMF Material Technology, Shenzhen.

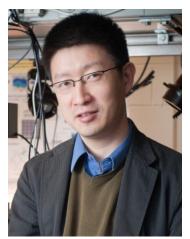


13:50-14:40 June 26 Plenary Presentation 5 Crystal hall, floor 5

■ Plenary Presentation 5

Title:Three dimensional photonic manufacturing: from architectured metamaterials to freeform optics design

Speaker: Nicholas Xuanlai FANG



Abstract: Three-dimensional metamaterial building blocks, through the combination of microscale geometric patterning and novel photo-responsive materials, show promise to revolutionize the ability to dissipate energy and manipulate wave propagation. Such materials are desirable for a broad array of applications for custom integrated optical assemblies incorporating mechanical, electronic, and optoelectronic components.

In this plenary talk, I will present our development of three-dimensional micro/nanofabrication techniques, to enable design and exploration of complex functional

micro-optical components. As an example, I will show that the microscale resolution and multi-material capabilities of projection microstereolithography as a versatile method of designing and fabricating architected components and assemblies for combined functions, including tunable thermal expansion, magnetic actuation/morphing, and transparent micro-scale bioreactors for tissue engineering. I will also discuss the potential of this additive manufacturing technology for rapid tooling of freeform optical elements with minimal alignment and assembly.

Biography: Nicholas Xuanlai Fang is currently a professor of Mechanical Engineering at MIT. He also serves as chief scientist of BMF Material Technologies, a technical startup spunoff from his research group of 3D micronanomanufacturing and nanophotonics at MIT. He received his BS and MS in physics from Nanjing University, and his PhD in mechanical engineering from University of California Los Angeles. Professor Fang's areas of research look at nanophotonics and nanofabrication. His recognitions include the ASME Chao and Trigger Young Manufacturing Engineer Award (2013); the ICO prize from the International Commission of Optics (2011); an invited participant of the Frontiers of Engineering Conference by National Academies in 2010; the NSF CAREER Award (2009) and MIT Technology Review Magazine's 35 Young Innovators Award (2008).



15:10-16:00 June 26 Plenary Presentation 6 Crystal hall, floor 5

■ Plenary Presentation 6

Title: Solar Adaptive Optics in IOE



Speaker: CHANGHUI RAO

Abstract:The Research and Development Adaptive Optics in China began in 1979. In 1980, the first laboratory on Adaptive Optics (AO) in China was established in the Institute of Optics and Electronics (IOE), Chinese Academy of Sciences (CAS). Until now, more than one hundred sets of AO systems had been successfully developed in the fields the astronomical observations, Confinement Facilities, and human vision sciences. communications, etc. This presentation concentrates on solar AO developments in IOE, CAS. In China, several solar AO systems had been built

since 2000. The first solar tilt-correction system was developed for the 43-cm solar telescope of Nanjing University in 2002. A 37-element AO experiment system for the 26-cm solar fine structure telescope at Yunnan Astronomical Observatories was built in 2009. Two generations of AO systems for NVST had been developed from 2012 to 2015. In order to enlarge the correction Field of View, a GLAO prototype system was built at the 1-meter NVST and made the first light in January 2016. In January 2017, a MCAO experiment system was set up and tested at the NVST on October 5th, 2017. Currently, a 1.8-m solar telescope with more than 400-element AO system and seven-wavelength high resolution imaging system from visible to near Infrared bands are being developed for solar physics research and space weather prediction. Moreover, a new MCAO system based on our proposed MCAO configuration with a high order ground layer adaptive optics and two low order high altitude corrections will be developed for the NVST as an a regularly operating instrument for scientific observations of the sun. In this talk, the solar AO systems will be introduced and the observation results are presented.

Biography: Prof. Changhui Rao was born in 1971. He received his BS degree in Electric Engineering from Wuhan University of Surveying and Mapping, his MASc and Ph.D. degrees in Optical Engineering from Institute of Optics and Electronics, Chinese Academy of Sciences, in 1993, 1997 and 2001 respectively. He is the member of SPIE and OSA. He has been engaged in the research on adaptive optics and solar high resolution imaging. More than 200 papers have been published. He won two National Technical Invention Awards, six Provincial Science and Technology Advancement Awards, National Excellent Doctoral Dissertation Award, Chinese Youth Science and Technology award, and Young Scientist award of Chinese Academy of Sciences. He is the vice director of the Institute of Optics and Electronics, Chinese Academy of Sciences, and the vice director of The Key Laboratory on Adaptive Optics, Chinese Academy of Sciences.



16:00-16:50 June 26 Plenary Presentation 7 Crystal hall, floor 5

■ Plenary Presentation 7

Title: The European Southern Observatory – giant optical telescopes of the present and future

Speaker: Adrian RUSSELL



Abstract: Present an overview of the current ESO Optical/IR facilities in Chile and the plans for their future instrumentation, followed by a status report on the construction of the 39m E-ELT on Armazones in Chile.

Biography: Dr Adrian Russell is Director of Programmes at the European Southern Observatory (ESO) in Garching, Germany.

Adrian graduated from the University of Sheffield in 1983 with a 1st Class Honours degree in Electrical and

Electronic Engineering, before undertaking a Ph.D. in Astronomy at the University of Cambridge (Mullard Radio Astronomy Observatory), on millimetre-wave heterodyne instrumentation and molecular-line studies of outflows in star-formation regions. In 1987 he joined the Royal Observatory Edinburgh (ROE), with a three-year tour of duty as a support scientist for the James Clerk Maxwell Telescope (JCMT) in Hawaii. In 1990 Adrian spent a two-year sabbatical with Professor Reinhard Genzel's group at the Max Planck Institute for Extraterrestrial Physics, working on very high frequency submillimetre instrumentation for the JCMT. He became Head of the JCMT Instrumentation Programme at the ROE in 1992, and was UK Project Manager for the Gemini twin 8-metre telescopes project from 1995 to 2001. In 1996 he was made Deputy Director of the ROE, and became the first Director of the U.K. Astronomy Technology Centre in Edinburgh in 1998. In January 2005, Adrian joined the US National Radio Astronomy Observatory as North American Project Manager for the Atacama Large Millimeter/submillimeter Array (ALMA), subsequently becoming the North American ALMA Project Director. He joined ESO in July of 2010.



Conferences and Chairs

Conference 1: Large Mirror and Telescopes

The theme of this conference is mainly about the research of large telescope and primary mirror, including the testing and manufacturing technology of primary mirror, the development and application of new materials, the related technologies of telescope, etc. The goal of this topic is to develop high-resolution astronomical telescopes and space telescopes, especially to develop the primary mirrors in telescope. This conference is to exchange the latest progresses and breakthroughs in the field of telescope, and discuss the application of new materials, new manufacturing and testing technologies of primary mirror. This topic is mainly divided into the following parts: large astronomical telescope and space telescope, light-weight mirror technology, deployable primary mirror and telescope, the testing and manufacturing technology of large primary mirror, supporting structure and system of primary mirror, new material of primary mirror.

- Mirrors for large astronomical and space telescopes
- Light-weight mirror technology
- Large deployable mirror and telescopes
- Innovative mirror and telescope designs
- Advanced testing methods for large mirror
- Support systems and structures
- New material for large mirrors
- Innovative concepts and designs

Conference Chairs:

Wenhan Jiang, Academician, Chinese Academy of Engineering; Institute of Optics and Electronics, CAS

Myung K. Cho, National Optical Astronomy Observatory (USA)

Hao Xian, Institute of Optics and Electronics, CAS

Bin Fan, Institute of Optics and Electronics, CAS



June 27 Conference 1: Large Mirror and Telescopes WuHou hall, floor 5

Date	Time	Name	Organization	Title	Remark
	08:30-09:20	Baoyan DUAN	Xidian University	On innovation, simulation, mode experiments and engineering of the five hundred meters aperture spherical radio telescope (FAST)	Invited
	09:20-09:50	Wei YANG	Institute of Optics and Electronics, Chinese Academy of Sciences	Imaging quality and analysis of membrane defraction telescope system	Invited
	09:50-10:20	Jiyou ZHANG	China Academy of Space Technology	Characteristics and optical manufacturing technology development of space optical elements	Invited
	10:20-10:30			Tea Time	
	10:30-10:45	Qichang AN	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	Mirror seeing and its evaluation	
June 27	10:45-11:00	Yufeng TAN		Application of scaling test in primary mirror for large aperture telescope	
	11:00-11:15	Donglin MA	Huazhong University of Science and Technology	A recommended conceptual optical system design for china's large optical-infrared telescope (LOT)	
	11:15-11:30	Bo WANG	Harbin Institute of Technology	Study of ultra-precision polishing of electroless nickel molding dies for the backdrop project of enhanced X-ray timing and polarimetry mission (eXTP)	
	11:30-11:45	Weiyan LI	Academy of Opto-electronics, Chinese Academy of Sciences	Thermal control focusing device for Space camera secondary mirror	
	11:45-12:00	Haifei HU	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	Research on bonding multiple pads to large mirrors	

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Conference Program

	CIVIA				
	12:00-13:00			Lunch	
	13:00-13:30	Zhanshan WANG	Tongji University	Development of nested conical approximation Wolter-I type X-ray focusing telescope with sub-arcminute angular resolution	Invited
	13:30-14:00	He DONG	Institute of Optics and Electronics, Chinese Academy of Sciences	Acquisition technology for optical ground stations in satelliteground quantum experiments	Invited
	14:00-14:30	Daojing LI	Institute of Electrics, Chinese Academy of Sciences	基于衍射与相阵原理的 10 米口径 新型激光雷达望远镜概念	Invited
	14:30-15:00	Haitao LIU	Institute of Optics and Electronics, Chinese Academy of Sciences	Asperic and freeform optical fabrication by computer controlled polishing technology	Invited
June 27	15:00-15:15	Haifei Hu	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	Epoxy strength reliability between metal and glass and feasibility for bonding face-down TMT M3M OAP	
	15:15-15:30	Yuming ZHOU	Beijing Institute of Space Mechanics and Electricity	Application of the gravity turning method for testing large aperture optical components	
	15:30-15:45			Tea Time	
	15:45-16:00	Ke ZHANG	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	Fabricating of 4m CIOMP-SiC mirror blank	
	16:00-16:15	Fei YANG	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	30 米望远镜第三镜设计进展	
	16:15-16:30	Haifeng CAO	University of Chinese Academy of Sciences	Analysis and correction about measurement error of edge sensor caused guide flexure applied in the support system assembly of TMT	



Conference 2: Advanced Optical Manufacturing Technologies

Advanced optical manufacturing is a technology using computer and precise machine with the help of optical CAD, digital optical measurement, etc., to manufacture optical components and systems in high-efficiency, low-cost and high-accuracy level. This conference chapter refers to optical design, ultra-precision optical processing, optical coating and opto-mechanical integration, ultra-precision polishing technology with nanometer accuracy. This chapter is to exchange the latest development and breakthrough in manufacturing technology and discuss optical design, processing and integration. This chapter mainly includes 12 sessions: Advanced optical manufacturing technologies, Aspheric design, Processing and metrology, High-precision freeform surface design, Machining and metrology, Ultra-precision optical processing, Optical thin film technology, Advanced diamond polishing technology, Magnetorheological optical processing, Advanced ion beam refinement and plasma technology, EEM and CVM processing technology, Optical technology, simulation software and tools, Integration and manufacturing of optoelectronic components, Opto-mechanical components and equipment.

- Advanced optical manufacturing technologies
- Aspheric optics design, manufacturing and testing
- Ultra-precision freeform surfaces design, manufacturing and testing
- Super-precision optical manufacturing
- Optical thin film coatings
- Advanced diamond turning technology
- Magnetorheological optical processing
- Advanced ion beam finishing and atmospheric plasma technology
- EEM (Elastic Emission Machining) and CVM (Chemical Vaporization

Machining) processing technology for super smooth surface with atomic lever

- Optical design, simulation software and tools
- Optoelectronics components, modules integration and manufacturing
- Optomechanics components and devices
- Laser manufacturing technology and equipment

Conference Chairs:

Junhua Pan, Academician, Chinese Academy of Engineering; Soochow University **William T. Plummer,** Member of the National Academy of Engineering, WTP Optics. Inc. (USA)

Shengyi Li, National University of Defense Technology

Qiao Xu, China Academy of Engineering Physics



June 27 Conference 2: Advanced Optical Manufacturing Technologies GaoXin hall, floor 5

Date	Time	Name	Organization	Title	Remark
	08:30-08:50	Shengfei WANG	China Academy of Engineering Physics	Formation and suppression of KDP surface defects generated in fly-cutting process	Invited
	08:50-09:10	Chenhui AN	China Academy of Engineering Physics	Dynamic error detection and error source analysis for ultra-precision flycutting machine tools	Invited
	09:10-09:25	Qianwen DUAN	Institute of Optics and Electronics, Chinese Academy of Sciences	Stability control of the electro-optical tracking system based on improved smith predictor	
June	09:25-09:40	Enguo CHEN	Fuzhou University	Study on the micro-dot distribution design and white-balance optimization of quantum-dot light guide plate for LCD backlight	
	09:40-09:55	Shengfei WANG	China Academy of Engineering Physics	Influences of fly-cutting parameters on the laser-induced damage performance of DKDP crystal	
	09:55-10:10	Weijie DENG	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	Reasearch on ion beam figuring system with five-axis hybrid mechanism for complex optical surface	
	10:10-10:20		Te	ea Time	
	10:20-10:35	Jiaqing XIE	Beijing Institute of Technology	Simulation and experimental study on the precision glass molding for microstructures on optical glass based on relaxationeffect	



Date	Time	Name	Organization	Title	Remark
				Regional effects and mechanisms	
	10.25 10.50	Qiongqiong	G. 1 II	of nanoparticle removal from Si	
	10:35-10:50	GU	Sichuan University	substrate by laser plasma shock	
				waves	
		Consider		Cutting force modeling of	
	10:50-11:05	Guoqing ZHANG	Shenzhen University	ultra-precision fly cutting of	
		ZHANG		groove	
	11:05-11:20	Xiaowen	Jilin University	Single-pulse writing of a concave	
	11.03-11.20	CAO	Jiiii Oliversity	microlens array	
				Dry-etching assisted	
	11:20-11:35	Xueqing	Tainahua University	femtosecond laser fabrication for	
	11:20-11:55	LIU	Tsinghua University	construction of three-dimensional	
				silicon microstructures	
			Taiyuan University of	Optimization of ultrathin silver	
	11:35-11:50	Linlin SHI		transparent electrode and its	
			Technology	application in organic solar cells	
	12:00-13:00			Lunch	
	13:00-13:20	Yun ZHANG	Institute of Optics and Electronics, Chinese Academy of Sciences	Advanced fabrication techniques	
				and applications on	
June				manufacturing sub-nanometer	Invited
27				accuracy aspheres	
	13:20-13:40	Shun ZHOU	Xi'an Technological University	The preparation, properties and	
				application of specialty optical	Invited
				thin film	
	12 40 12 55	Yaguo LI	China Academy of	Ion beam planarization of	
	13:40-13:55		Engineering Physics	diamond turned metal surface	
			Dalian Institute of	Research on super smooth	
	12.55.14.10	Tianxiang	Chemical Physics,	aspheric surface fabrication of	
	13:55-14:10	SUN	Chinese Academy of	computer controlled optical	
			Sciences	surfacing	
	14 10 14 25	Jiachang	Beijing University of	New taper optics for excimer	
	14:10-14:25	GUO	Technology	laser convergence	
				Chiral nanostructures enabled by	
	14:25-14:40	FeiXIE	Jinan University	monochromatic dual-beam	
				super-resolution lithography	
				Improvement of the surface	
	14.40 14 55	Defeng	China Academy of	shape error of the pitch lap to a	
	14:40-14:55	LIAO	Engineering Physics	deterministic continuous	
				polishing process	
	1455 15 10	E : DILLING	China Academy of	Research on the highly accurate	
	14:55-15:10	Fei ZHANG	Engineering Physics	deposition of films on wedged	

Conference Pro	gram
sampling mirrors by e-beam	

	UIVIA			Conference i rogram
				sampling mirrors by e-beam
				evaporation
				Inert gas packaging of InGaAs
	15:10-15:25	Defeng MO		detector with multistage
				thermoelectric cooler
	15:25-15:40		Те	a Time
		Jianpeng	National University of	The opto-mechanical design and
	15:40-15:55	WANG	Defense Technology	analysis of aluminum - based
				space camera
		Liquan	China Academy of	Kilo-joule Laser facility back
	15:55-16:10	WANG	Engineering Physics	lighting terminal system
		Huijun	Beijing Institute of Space	Study on edge-trimming
	16:10-16:25	WANG	Mechanics and Electricity	experiment of reflective mirror
				Experimental investigation on
	16:25-16:40	Zhengfei	Beijing University of	processing conical holes with
		WANG	Technology	248nm excimer laser
_	16:40-16:55	Chen DAI	Beijing Institute of Space	Optical surfacing and testing of
June			Mechanics and Electricity	φ628mm aspheric SiC mirror
27	16:55-17:10	Fengfeng SHEN	Shanghai Institute of	Ultra-precision optical
			Optics and Fine	processing and simple laser
			Mechanics, Chinese	performance of Yb:LuScO ₃
			Academy of Sciences	crystal
			Chengdu Fine Optical	Molecular growth kinetics
	17:10-17:25	Wei YANG	Engineering Research	analysis associated with the
			Centre	sol-gel coatings uniformity
			Chengdu Fine Optical	Investigation on the control
	17:25-17:40	Xiang HE	Engineering Research	technique of surface roughness
			Centre	for silicate glass
		Wanli	National University of	Research on combined curface
	17:40-17:55	ZHANG	Defense Technology	modification of single crystal
		ZHANO	Defense Teenhology	silicon cylindrical mirror
			National University of	Fabrication of a high precision
	17:55-18:10	Xinlei LI	Defense	aluminum alloy cylinder mirror
			Detelise	with combined polishing process
		Jianpeng	National University of	The opto-mechanical design and
	18:10-18:25	WANG	Defense Technology	analysis of aluminum - based
		WAINU	Detense reciniology	space camera



June 28 Conference 2: Advanced Optical Manufacturing Technologies GaoXin hall, floor 5

Date	Time	Name	Organization	Title	Remark
			National	High-precision & low-defect	
			University of	manufacturing technology of	
	08:00-08:20	Feng SHI	Defense	single-crystalline silicon cylindrical	Invited
			Technology	reflector	
			a	A predictive model of critical depth	
	08:20-08:40	Deping YU	Sichuan	of cut for ultrasonic elliptical	Invited
			University	vibration cutting of brittle materials	
				Effect of weld toe geometry on	
	00.40.00.55			fatigue strength of nickel based	
	08:40-08:55	Jingling YU		C-276 weld joint by laser welding	
				with filler wire	
			Chengdu Fine	Growth properties and optical	
	00.55 00 10	Yaowei YU	Optical	properties for HfO2 thin films	
	08:55-09:10	Yaowei YU	Engineering	deposited by atomic layer	
			Research Center	deposition	
	00 10 00 25	Xiangzhao		Ultra-precision robotic sub-aperture	
	09:10-09:25	ZHANG	Fudan University	polishing of curved mirrors	
	09:25-09:40	Magomed A. ABDULKADY ROV	ICC Lastles sin a	Defining of aspherical surfaces	
June			JSC Lytkarino	decentering with respect to the	
28			Optical Glass	geometrical center by means of	
			Factory	CGH	
			Changchun		
			Institute of		
			Optics, Fine	Ion beam figuring high gradient	
	09:40-09:55	Wa TANG	Mechanics and		
			Physics, Chinese	optical aspherical surface	
			Academy of		
			Sciences		
	09:55-10:10			Tea Time	
			CSIR-Central		
	10:10-10:25	Vinod	Scientific	Development of flexible pad	
	10.10-10.23	MISHRA	Instruments	polishing setup for freeform optics	
			Organisation		
			Shanghai Institute		
			of Optics and Fine	December of the surface of	
	10:25-10:40	Jun CAO	Mechanics,	Research of the mist phenomenon	
			Chinese Academy	on Nd-doped glass surface	
			of Sciences		

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Conference Program

	UIVIA			Conference i rogram
	10:40-10:55	Zhuochen MA	Jilin University	Femtosecond laser direct writing enabled fabrication and integration of metallic micro/nanostructures
	10:55-11:10	Zhibin WANG	西安应用光学研 究所	Selection the coating for low Tg glass precision glass molding
June 28	11:10-11:25	Bo ZHONG		Relationship between slurry flow pattern and removal characteristics based on a novel polishing tool
	11:25-11:40	Zhihai PANG	Xi'an Institute of optical precision machinery, Chinese Academy of Sciences	Design and fabrication of CGH for 820mm diameter tertiary mirror surface figure testing without center hole
	11:40-11:55	Lele REN	Harbin Institute of Technology	Investigation on the compression behavior of polishing lap in continuous polishing
	11:55-12:10	Zuocai DAI	National University of Defense Technology	Investigation of fused silica surface etching during obliquely incident inductively coupled plasma
	12:10-12:25	Zhifan LIN	National University of Defense Technology	Effect of magnetorheological finishing on laser damage properties of calcium fluoride



Conference 3: Optical Test, Measurement Technology and Equipments

Optical metrology is to gain physical quantities (profile, figure, roughness, etc) of tested object by analyzing and processing optical signal (intensity, phase and polarization, etc). Optical metrology and instrument, the foundation of modern optical engineering and industry, promotes advanced optical manufacturing technology. This chapter is focused on the latest development and the future trend in optical metrology and instrument for advanced optical manufacturing, including new theory, new principle, new technology, new method, new application and new instrument. This chapter consists of 8 sessions: freeform surface metrology, aspheric metrology, ultra-precision optical metrology, ultra-smooth surface metrology, infrared metrology, surface-damage detector, nanometer testing, new testing technology and instrument, simulation model.

- Test for optical freeform surface
- Test for aspheric optical surface
- Test for super-precision optical surface
- Measurement for super smooth surface
- Measurement of optical thin film
- Test with infrared technologies
- Optical contamination
- Optical test and measurement for nanometer technology
- New and innovative metrology and equipment
- Analysis and modeling tools/software

Conference Chairs:

Yudong Zhang, President of Chengdu Branch of Chinese Academy of Sciences Wei Gao, Tohoku University (Japan)
Min Xu, Fudan University



June 27 Conference 3: Optical Test, Measurement Technology and Equipments Qing Yang hall, floor 5

Date	Time	Name	Organization	Title	Remark		
				Long Focal-length			
	00 20 00 50			Measurement using divergent	.		
	08:30-08:50	Jian BAI	Zhejiang University	beam and two gratings of	Invited		
				different periods			
		G1	N	Variable optical null			
	08:50-09:10	Shanyong	National University of	technique towards flexible	Invited		
		CHEN	Defense Technology	surface interferometry			
		Chao	University of Electronic	Nitride semiconductor			
	09:10-09:30	WANG	Science and Technology	epitaxial growth on-line	Invited		
		WANG	of China	monitoring technology			
				The laser screen technology			
			Army Academy of	research of the firing			
	09:30-09:45	Da XU	Armored Forces	dispersion and initial velocity			
			Armored Porces	test of the high shooting			
				frequency weapons			
		Juan DU	Zhejiang University	Composition and accuracy			
	09:45-10:00			analysis of interferometric			
				star tracker			
June	10:00-10:15	Jingdong ZHANG	Chongqing University	High performance φ-OTDR			
27				for distributed vibration			
				sensing based on optical pulse			
				modulation			
		Guolu YIN	Chongqing University	Intensity-modulated			
	10:15-10:30			directional torsion sensor			
	10.13 10.30			based on in-line optical fiber			
				Mach-Zehnder interferometer			
	10:30-10:40	Tea Time					
				Pump frequency modulated			
		Hua		fast BOTDA for high spatial			
	10:40-10:55	ZHENG	Chongqing University	resolution/ long-distance			
		ZIZI (O		distributed dynamic strain			
				sensing			
		Shaoqi	Beijing Institute of	Research on surface quality			
	10:55-11:10	ZENG	Control Engineering	measurement technology for			
		ZEITO	Control Engineering	small surface structure			
		Xiting	Beijing Institute of Space	Research on computer-aided			
	11:10-11:25	ZHAO	Mechanics and Electricity	alignment for an afocal			
				off-axis optical system			



				Full field scanning	
		Xiangchao ZHANG		measurement of surface	
	11:25-11:40		Fudan University	defects using flexible digital	
				holographic microscopy	
				Gravity deformation of	
		Dongcheng		high-precision subaperture	
	11:40-11:55	WU		stiching under the three-point	
				support	
	11:55-13:00		Lï	ınch	
			Institute of Optics and	Interferometric measurement	
	13:00-13:20	Haiyang	Electronics, Chinese	of thin-parallel plate optics	Invited
		QUAN	Academy of Sciences	with low uncertainty	
				Research on adaptive	
		Zhiliang		interferometric examination	
	13:20-13:40	ZHAO	Chengdu TYGGO	of complex vibration	Invited
				environment	
			Shanghai Institute of	Research of suppressing stray	
June	13:40-13:55	Yang WANG	technical Physics,Chinese	light of cold shield with	
27			Academy of Sciences	different black coating	
27	13:55-14:10	Lei SHI		Polarization-resolved	
			Fudan University	momentum-space imaging	
				spectroscopy	
		Xing PENG	Fudan University	A preliminary study of in-situ	
	14:10-14:25			defects measurement for	
				additive manufacturing based	
				on multi-spectrum	
				3D measurement of	
	14:25-14:40	Panyu	Fudan University	microstructures by using	
		ZHOU		plenoptic microscope	
			Beijing Institute of	Point target space location	
	14:40-14:55	Jidong LIU	Technology	measurement methods based	
			reciniology	on ultra-sparse image	
				Research on testing	
	14:55-15:10	Cong	Beijing Institute of Space	technology of large aspheric	
	14.33-13.10	WANG	Mechanics and Electricity	lens in the phase of optical	
				grinding	
			Changchun Institute of	Study on pentaprism scanning	
	15:10-15:25	Erhui QI	Optics, Fine Mechanics	technology for testing large	
	15.10 15.25	2.1101 Q1	and Physics, Chinese	flat mirrors	
			Academy of Sciences	1144 11111013	
	15:25-15:35		Tea	Time	

Conference	Program
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	<u>UIVIA I</u>			somerence i rogram
June 27	15:35-15:50	Yao HU	Beijing Institute of Technology	Flatness and diffractive wavefront measurement of liquid crystal computer-generated hologram based on photoalignment technology
	15:50-16:05	Jianheng HUANG	Shenzhen University	X-ray phase-contrast imaging using cascade Talbot-Lau interferometers
	16:05-16:20	Guanghua YANG	Academy of Opto-Electronics Chinese Academy of Sciences	The angular measurement of the motion direction of the stack stages based on the dual-frequency laser interferometer
	16:20-16:35	Jing MA	Academy of Opto-Electronics Chinese Academy of Sciences	Analyze the influence of grating constant error on measurement accuracy of grating displacement sensor
	16:35-16:50	Xinxue MA	Changchun Institute of Optics, Fine Mechanics and Physics, Chinese Academy of Sciences	The research on phase-diversity phase retrieval in testing the large-aperture telescope
	16:50-17:05	Ruiyang WANG	Sichuan University	Study on eliminating the effect of parasitic reflection on deflectometry measurement of planar optical element surface figure
	17:05-17:20	Yingying ZHANG	Hunan University	High accuracy determination of viscoelastic properties of optical glass in lens molding process
	17:20-17:35	Jie LI	Research Center of Laser Fusion, China Academy of Engineering Physics	Optimal modified lateral shearing interferometer for in-line damage morphology measurement
	17:35-17:50	Zhigeng FEI	Zhengzhou University of Light Industry	The inner-cone angle measurement of aero-engine nozzle based on conoscopic holography
	17:50-18:05	Lei ZHANG	Anhui University	Optical free form surface metrology in adaptive polarized interferometry



June 28 Conference 3: Optical Test, Measurement Technology and Equipments JinFuRong hall, floor 6

Date	Time	Name	Organization	Title	Remark
			University of	Inspection of specular object	
	13:00-13:15	Huimin	Electronic Science	surface defects eliminating dust	
	13.00-13.13	YUE	and Technology of	based on polarized fringe structured	
			China	illumination	
			Xi'an Institute of Optics and Precision Mechanics	A Mueller matrix measurement	
	13:15-13:30	Haijuan JU		technique based on a	
				division-of-aperture polarimetric	
				camera	
			Research Center of Laser Fusion, China Academy of Engineering Physics	Multi-wavelength investigation of	
		Yinbo		the influence of polarization	
	13:30-13:45	ZHENG		orientation on bulk damage	
		ZHENG		resistance of type I double KDP	
				crystals	
			Research Center of	Fresnel zone plate method for	
	13:45-14:00	Xiaohong	Laser Fusion, China	measuring lens transmission	
	13.43 14.00	WEI	Academy of	wavefront power spectral density	
			Engineering Physics	waverront power spectral density	
June 28	14:00-14:15	Qiunong HE	Institute of Optics and Electronics, Chinese Academy of Sciences A feedforward control method for optical tracking system based on eddy current sensor	A feedforward control method for	
				cady carrent sensor	
		Guoqing GU	Yancheng Institute of Technology	An integrated single-camera digital	
	14:15-14:30			speckle pattern interferometry for	
				simultaneous full-field 3D	
				displacements measurement	
	14:30-14:45	Shuiqin WU	Institute of Optics	Research of the fiber coupling efficiency based on SPGD control algorithm	
			and Electronics,		
			Chinese Academy of		
			Sciences	-	
	14:45-15:00	Xiangdong ZHOU		Description of complex optical	
			Zhejiang University	surface based on sparse radial basis	
				function approximation with	
				spatially variable shape parameters	
	15:00-15:15 15:15-15:30	Kai SHI	Xi'an Technological University	Thin film thickness measurement	
				based on laser heterodyne	
				interferometry	
		Hongzhen	Research Center of	Measurement for the structure of	
		JIANG	Laser Fusion,	microcosmic defects on optical	

A2018

Conference Program

	<u>UIVIA I</u>	Conference 110gruin			
June 28			Chinese Academy of	surface with digital holographic	
			Engineering Physics	microscopy	
	15:30-15:40	1		Tea Time	
	15:40-15:55	Zhihai PANG	Xi'an Institute of optical precision machinery, Chinese Academy of Sciences	The study of free form optical elements corrected aberrations of optical system	
	15:55-16:10	Guixia WANG	Xi'an Technological University	Spectrum-analysis of parameters associated with laser-induced air breakdown plasma	
	16:10-16:25	Lei ZHANG		New indoor distance simulation detection device	
	16:25-16:40	Dali Ramu BURADA	Indian Institute of Technology	Challenges involved in metrology of freeform optics	
	16:40-16:55	Li WU	Xi'an Institute of optical precision machinery, Chinese Academy of Sciences	Research on key technology of the optical measurement device—used in liquid oxygen tank of carrier rocket	
	16:55-17:10	Zijuan JI	Hubei University of Education	A variable divergence angle laser beam shaping system with aspherical lenses	
	17:10-17:25	Zhenzhen XU	Fudan University	Research and design of functional microstructures with directional transport for bionic microfluidics	



Conference 4: Micro/Nano Optics and Subwavelength Electromagnetics

This conference chapter refers to the study of various novel features of light at the micro-nanometer scale, including the generation, propagation, modulation, conversion and detection of light. The research objection of this conference chapter is to manipulate and control photons at micro-nanometer scale, and develop optical devices with all-light integration, small footprint, high integration, fast speed and low-energy consumption, which could provide physical platform and technical support for the next generation of information technology. The goal of this chapter is to exchange recent development and breakthrough in the micro-nano optics, including the fundamental physics governing their operation, the device design and fabrication, the novel application. This conference chapter manly includes seven session parts:

- Micro/Nano manufacturing technology
- Super-resolution imaging and high sensitivity sensing
- Surface plasmons and metamaterials
- Metasurfaces and planar optics
- Nonlinearity, quantum and topological optics
- Subwavelength electromagnetics
- Fiber-optical waveguide microstructure

Conference Chairs:

Xiangang Luo, Institute of Optics and Electronics, CAS

Min Gu, Royal Melbourne Institute of Technology University (Australia)

Xiaodi Tan, Beijing Institute of Technology

Ting Xu, Nanjing University

Zheyu Fang, Peking University

Xinbin Cheng, Tongji University

Zinan Wang, University of Electronic Science and Technology of China

Mingbo Pu, State Key Laboratory of Optical Technologies on Nano-Fabrication and Micro-Engineering, Institute of Optics and Electronics, CAS

Micro-Engineering, institute of Optics and Electronics, CAS

Xiong Li, State Key Laboratory of Optical Technologies on Nano-Fabrication and Micro-Engineering, Institute of Optics and Electronics, CAS



Conference 6: Extreme Manufacturing Technology

Extreme manufacturing technologies focus on the manufacturing structures, devices and systems with extreme dimensions and properties under extreme conditions, including micro/nanoscale manufacturing, ultra-precision manufacturing, complexed manufacturing and giant system manufacturing. The advances of laser technology and its integration with the other advanced manufacturing technologies lead to the generation of various advanced technologies for the manufacturing of functional micro/nanoscale, giant scale and complexed structures, ultra-precision manufacturing and so on. Furthermore, the emergent technologies including complex energy source manufacturing, four dimensional printing technology as well as manufacturing in orbit will expand the applications of extreme manufacturing technology.

- Manufacturing with extreme condition
- Manufacturing for extreme scale
- Manufacturing with complex energy source
- Manufacturing for complex structures
- Manufacturing in orbit (zero-gravity)
- Four-dimensional printing technology
- Application of extreme manufacturing

Conference Chairs:

Xuanming Duan, Chongqing Institute of Green and Intelligent Technology, CAS

Lin Li, University of Manchester (UK)

Dicheng Li, Xi'an Jiaotong University

Lan Jiang, Beijing Institute of Technology

Wenwu Zhang, Institute of Advanced Manufacturing, Ningbo Institute of Industrial Technology, CAS



June 27 Conference 4: Micro/Nano Optics and Subwavelength Electromagnetics JinJiang hall, floor 5

Date	Time	Name	Organization	Title	Remark
	08:30-09:00	Chengwei QIU	National University of Singapore	Intelligent metasurfaces for human and biomedical applications	Invited
	09:00-09:30	Lei ZHOU	Fudan University	High-efficiency, multifunctional, and tunable metasurfaces	Invited
	09:30-10:00	Xiangping LI	Jinan University	Diatomic metasurfaces for vectorial and multifunctional holography	Invited
	10:00-10:30	Lei ZHANG	Northwestern Polytechnical University	Manipulation of light with mode hybridization	Invited
	10:30-10:45			Tea Time	
	10:45-11:00	Guoxing ZHENG	Wuhan University	A 4*4 beam splitter based on geometric metasurfaces	
	11:00-11:15	Xue JIANG	Chongqing University	A THz quarter-wave plate based on all-dielectric metasurface	
June	11:15-11:30	Zhongquan WEN	Chongqing University	A terahertz wave imaging lens based on metasurfaces	
27	11:30-11:45	Siqi LI	Xi'an Institute of Optics and Precision Mechanics, Chinese Academy of Sciences	Complete phase and amplitude control on all-dielectric metasurface	
	11:45-12:00	Qingkun XIE	Xi'an Institute of Optics and Precision Mechanics, Chinese Academy of Sciences	Practical super-oscillation lens excogitation for far field complex objects imaging	
	12:00-13:00			Lunch	
	13:00-13:30	Hansik YUN	Seoul National University	Plasmonic and metasurface nanostructures for optical imaging	Invited
	13:30-14:00	Tao LI	Nanjing University	Dispersion engineering in metasurfaces for applicable optical devices	Invited
	14:00-14:30	Jiaming HAO	Shanghai Institute of Technical Physics of the Chinese	Spatial and frequency selective plasmonic metasurfaces for long wavelength infrared spectral	Invited

A2018

Conference Program

	UIVIA			Comerciae 110	0
			Academy of	region	
			Sciences		
			C W	Functional nanostructures for	
	14:30-15:00	Zhangkai	Sun Yat-sen	subwavelength image and its	Invited
		ZHOU	University	application	
	15.00.15.15	II CHEN	Chongqing	Sub-diffraction focusing of THz	
	15:00-15:15	Hao CHEN	University	wave with a dielectric metalens	
	15:15-15:30			Tea time	
	15 20 16 00	T. DIVIG	W. 1 II	Plasmon-directed polymerization	T '. 1
	15:30-16:00	Tao DING	Wuhan University	with subwavelength precision	Invited
T				Non-lithographic fabricating	
June 27	16:00-16:30	Wenxin	Technische	plasmonic metastructures and	T '. 1
21		WANG	Universit ät Ilmenau	their second-order optical	Invited
				nonlinearities	
	16:30-17:00		Institute of Optics		
		Xiaoliang MA	and Electronics,	Polarization manipulation based	T '. 1
			Chinese Academy of	on metasurface	Invited
			Sciences		
				Ultrathin planar metalens for	
	17:00-17:15	Fei QIN	Jinan University	sub-diffractive limit focusing and	
			·	imaging	
				A high-precision optical fiber	
	17.15.17.20	Wangwang	North University of	adaptive lithography method for	
	17:15-17:30	LI	China	vertical integration of optical	
				fiber and planar chip	
		Linkona	Paijing Institute of	Research on properties of	
	17:30-17:45	Jinliang	Beijing Institute of	anisotropic gratings fabricated by	
		ZANG	Technology	polarization holography	
		Shaolin	South China	Rapid prototyping of infrared &	
	17:45-18:00	ZHOU	University of	terahertz metasurface device by	
		ZHUU	Technology	one-step photo-lithography	

June 28 Conference 4: Micro/Nano Optics and Subwavelength Electromagnetics Conference 6: Extreme Manufacturing Technology JinJiang hall, floor 5

Date	Time	Name	Organization	Title	Remark
June	08:30-09:00 Lan JIANG Beijing Institute of Technology	Multiscale measurement of electron dynamics in femtosecond laser- material interactions	Invited		
28	09:00-09:30	Minglie HU	TianjinUniversity	Fiber femtosecond laser with few cycle pulse and it application in micro/nano structure	Invited

		e rrogra			
		Meiling	Technical Institute	Super-resolution achieved in	
	09:30-10:00	2:30-10:00 ZHENG	of Physics and	femtosecond laser	Invited
			Chemistry	micro/nanofabrication technique	
				Laser beam welding of high	
	10:00-10:30	Rongshi	Beijing University	strength aluminum-lithium	Invited
		XIAO	of Technology	alloys—problems and solutions	
	10:30-10:45			Tea Time	
			Shanghai Institute		
			of Technical		
	10:45-11:00	Jingsong WEI	Physics of the	Laser heat-mode lithography:	
	10.43-11.00	Jingsong WEI	Ī -	principle and methods	
			Chinese Academy		
			of Sciences		
			Chongqing Institute	Multi-photon laser lithography of	
	11:00-11:15	Hongzhong	of Green and	AR-N4340 photoresist with spatial	
	11.00 11.10	CAO	Intelligent	resolution at nanoscale	
			Technology, CAS	resolution at hanoscare	
				Effect of water cooling on the	
	11:15-11:30	Bo CHENG	Dalian University of Technology	microstructure and property of laser	
_				welding of nickel-based	
June 28				alloy/austenitic stainless steel with	
				filler wire	
				Application of femtosecond laser	
	11:30-11:45	Zhennan TIAN	Jilin University	direct writing technology in	
				fabrication of micro optical devices	
				Sub-wavelength anti-reflective	
			Jilin University	structures on sapphire fabricated by	
	11:45-12:00	Qiankun LI		femtosecond laser writing and	
				_	
	12.00.12.00			etching	
	12:00-13:00		T	Lunch	T
		Jianwen	Sun Yat-sen	All-dielectric valley photonic	
	13:00-13:30	DONG	University	crystals: paving the way to	Invited
				topological nanophotonics	
	13:30-14:00	Renmin MA	Peking University	Plasmonics: friend or foe for laser	Invited
	13.30-14.00	Keiiiiiii WIA	reking University	miniaturization?	mvited
			Institute of Optics		
	1400 1430)	and Electronics,	Extraordinary Young's interference	
	14:00-14:30	Mingbo PU	Chinese Academy	and its application in metasurface	Invited
			of Sciences	fabrication	
			The Hong Kong	Optical chirality generation and	
	14:30-15:00	Dangyuan	Polytechnic	amplification in plasmonics	Invited
		LEI	University	nanostructures	
			Shanghai Institute	Nonlinear absorption and nonlinear	
	15:00-15:30	Jun WANG	of Optics and Fine	refractive index of 2D transition	Invited
		<u> </u>	of Optics and Fine	remactive index of 2D transition	

	I UIVIA	 		Conference Frog	51 am			
			Mechanics, Chinese Academy of	metal dichalcogenides				
			Sciences					
	15:30-15:45	Tea time						
	15:45-16:15	Xifeng REN	Shanghai Institute of Technical Physics of the Chinese Academy	Quantum plasmonic N00N state in a silver nanowire	Invited			
			of Sciences					
	16:15-16:30	Dezhuan HAN	Chongqing University	Topological interface states in system of spoof surface plasmon polaritons				
June 28	16:30-16:45	Guangxing WU	Nanjing University	Strain tunable surface second harmonic generation in optical fiber nanowires				
	16:45-17:00	Xusheng CAI	Tsinghua University	Suspended-graphene-based cavity optomechanical system				
	17:00-17:15	Kangle YONG	Sichuan University	Thermal blooming effect of plus vortex pulse laser beam propagating through the atmosphere				
	17:15-17:30	Siqing ZHANG	Xidian University	Theoretical study of strained black phosphorus photodetector integrated with silicon waveguide				
	17:30-17:45	Xueying OUYANG	Jinan University	Saturation scattering inspired single-wavelength super-resolution imaging of gold nanoparticles				
	17:45-18:00	Si ZHANG	Fudan University	Broadband enhancement of photoluminance from colloidal metal halide perovskite nanocrystals on plasmonic nanostructured surfaces				

June 28 Conference 4: Micro/Nano Optics and Subwavelength Electromagnetics WuHou hall, floor 5

Date	Time	Name	Organization	Title	Remark
June		Zhiyuan LI	South China University of Technology	Mesoscopic and microscopic strategies for engineering plamon enhanced Raman scattering	Invited
28	09:00-09:30	Shunping ZHANG	Wuhan University	Nanocavity plasmons: strong light-matter interaction and sensing	Invited

<u></u>	iter ente	e Progra	am	OIVI	<u>AII</u>
	09:30-10:00	Chongjun JIN	Sun Yat-sen University	Micro-structured plasmonic materials for optical hydrogen sensors and polarization rotators	Invited
	10:00-10:15	Jianping SHI	Anhui Normal University	Surface plasmon resonance in bowl-like pore array of Ag-Au alloy and Sactivity research	
	10:15-10:30	Long WEN	Jinan University	Surface lattice resonance enhanced optical sensor with high sensitivity and direct electrical-readout	
	10:30-10:45		7	rea time	
	10:45-11:15	Yu LUO	Nanyang Technological University	Plasmonics using structured dispersion	Invited
	11:15-11:45	Hua LU	Northwestern Polytechnical University	Fano resonances in plasmonic nanostructures	Invited
	11:45-12:00	Yihong FANG	Guangdong University of Technology	Fano resonance based on a subwavelength semi-annular-rectangular cavity resonator	
	12:00-13:00			Lunch	•
June 28	13:00-13:30	Weiqiang DING	Harbin Institute of Technology	Enhanced optical manipulation using the eigenmodes of photonic structures	Invited
	13:30-14:00	Lei SHI	Fudan University	Observation of polarization vortices in momentum space	Invited
	14:00-14:30	Xiong LI	Institute of Optics and Electronics, Chinese Academy of Sciences	Catenary optics and its applications	Invited
	14:30-15:00	Jicheng WANG	Jiangnan University	Perfect absorption and magnetic polaritons of graphene-based silicon carbide grating structures	Invited
	15:00-15:30	Yun LAI	Nanjing University	Optical "anti-doping" effect induced by parity-time symmetry	Invited
	15:30-15:45		7	Tea time	
	15:45-16:00	Yunping QI	Northwest Normal University	Extraordinary optical transmission of "回" shaped metal nanocomposite structures	
	16:00-16:15	Yang LU	Lanzhou University	Long range symmetrical hybrid plasmonic waveguide with high confinement and centimeter-scale propagation	

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June 28	16:15-16:30	Yan LIU	Xidian University	Highly doped silicon graded grating strips for rainbow trapping at the terahertz range	
	16:30-16:45	Yunyun MU	Beijing University of Technology	Gold-silver alloy nanoclusters assembled waveguided metallic photonic crystals	
	16:45-17:00	Xin YE	China Academy Of Engineering Physics	The mechanism of regulating electromagnetism field by subwavelength structure	
	17:00-17:15	Min WANG	Northwestern Polytechnical University	Enhance the absorption of organic-inorganic perovskite film by nano-surface engineering	
	17:15-17:30	Jinglong ZHANG	Tongji University	Ultrabroadband reflector based on double layer subwavelength gratings	



Conference 5: Meta Surface-wave and Surface Plasmon Lithography

Recently, extraordinary electromagnetic wave phenomena associated with noble metals, semiconductors and subwavelength structures inspired a great deal of interests, like enhanced optical transmission, light beaming, directional light propagation, localized light enhancement, Fano resonances. Deep investigations reveal that those abnormal behaviors are usually resulted from the specific surface and/or localized electromagnetic wave modes, such as surface plasmon polaritons, localized surface plasmons and Bloch waves, which could be generally termed as metasurface waves. The mechanisms and principles behind those behaviors help us to engineer complex light features in subwavelength scale, including wavevector, amplitude, phase, angular momentum and spectrum, simply by actively and passively manipulating geometrical structures and material properties. Those methods were further utilized to design a great number of artificial materials and devices with variant innovative functionalities, like negative refraction materials, perfect lenses, perfect light absorption, invisible cloaks, vector beams and surface enhanced Raman spectrum, which have been applied in super resolution imaging, sub-diffraction optical lithography, ultra-thin absorbers and planar subwavelength antennas etc. In this conference, we cordially invite researchers in those areas to present their latest investigation results, share and enjoy achievements, discuss and preview future developments and applications.

- Super-resolution imaging
- Super-resolution lithography
- Vectorial electromagnetic manipulation
- Ultra-thin absorption
- Metasurface antenna
- Liquid crystal based light control technology

Conference Chairs:

Minghui Hong, National University of Singapore (Singapore)

Mohsen Rahmani, Australian National University (Australia)

Song Hu, Institute of Optics and Electronics, CAS

Changtao Wang, State Key Laboratory of Optical Technologies on Nano-Fabrication



and Micro-Engineering, Institute of Optics and Electronics, CAS

Xiaoliang Ma, State Key Laboratory of Optical Technologies on Nano-Fabrication and Micro-Engineering, Institute of Optics and Electronics, CAS

Cheng Huang, State Key Laboratory of Optical Technologies on Nano-Fabrication and Micro-Engineering, Institute of Optics and Electronics, CAS

Qing Zhao, University of Electronic Science and Technology of China

June 27 Conference 5: Meta Surface-wave and Surface Plasmon Lithography ChengHua hall, floor 5

Date	Time	Name	Organization	Title	Remark	
	08:00-08:30	Mohsen RAHMANI	The Australian National University	Nonlinear nanophotonics via metallic,dielectric, and semiconductor nanostructures	Invited	
	08:30-09:00	Douguo ZHANG	University of Science and Technology of China	Wide field super-resolution imaging of plasmons propagating along a silver nanowire	Invited	
	09:00-09:30	Gang CHEN	Chongqing University	A far-field optical label-free super-oscillation microscopy based on sub-diffraction quasi-nondiffraction beam	Invited	
June	09:30-10:00	Fangwen SUN	University of Science and Technology of China	Super-resolution microscopy for quantum sensing with NV center in diamond	Invited	
27	10:00-10:30	Luru DAI	The National Center for Nanoscience and Technology	None user biased single molecule identification algorithm in super resolution imaging and other methods	Invited	
	10:30-10:45		Tea	Time		
	10:45-11:15	Yanqin WANG	Institute of Optics and Electronics, Chinese Academy of Sciences	Far field imaging with super oscillation optics	Invited	
	11:15-11:45	Lianwei CHEN	National University of Singapore	Meta-surfaces: breaking the limits in imaging and information processing	Invited	
	11:45-12:00	Zhixiang WU	Chongqing University	Sub-diffraction hollow ring generated by super-oscillatory lens based on high transmission dielectric metasurface		
	12:00-13:00		Lu	ınch		

COI	merence Program			OWALL	
	13:00-13:30	Weijie KONG	Institute of Optics and Electronics, Chinese Academy of Sciences	Surface imaging by ultra-thin plasmonic illumination	Invited
		Ruxue	University of Science and	Excitating and shaping the	
	13:30-13:45	WANG	Technology of China	Bloch surface waves	
				Super resolution imaging based	
	13:45-14:15	Zongsong	Huazhong University of	on triexciton fluorescence of	Invited
		GAN	Science and Technology	quantum dot	
		T .	TT :	Near field optical lithography	
	14:15-14:45	Liang	University of Science and	using ultra-small gap bowtie	Invited
		WANG	Technology of China	apertures	
			Institute of Optics and	Plasmonic lithography beyond	
	14:45-15:15	Changtao	Electronics, Chinese	diffraction limit and its	Invited
		WANG	Academy of Sciences	applications	
	15:15-15:25		Tea	Time	
				Micro/nano fabrication and	
	15:25-15:55	Jing FENG	Jilin University	light manipulation in organic	Invited
				optoelectronic devices	
	15:55-16:25	Qidai CHEN	Jilin University	High performance Micro-optics	
June				fabricated by femtosecond	Invited
27				lasers	
21	16:25-16:55			Metal nano-honeycomb	
		Fang LIU	Tsinghua University	fabricated by colloidal	Invited
				assembly and	invited
				femtosecond-laser annealing	
			TianjinUniversity	Ion beam nano manufacturing	
	16:55-17:25			and its application in nano	Invited
		XU		optics	
				Surface plasmon cavities on	
	17:25-17:55	Tian	Shanghai Jiaotong	optical fiber end-facets for	Invited
	17.23-17.33	YANG	University	biomolecule and ultrasound	Illvited
				detection	
	17:55-18:10	Gaofeng	Chongqing University	Super resolution lithography	
	17.55-16.10	LIANG	Chongqing University	with a photonic crystal structure	
				Improvement of resolution and	
	18:10-18:25	Xuexin	Tianma Microelectronics	uniformity by FX-68s	
	16.10-16.23	LAN	Co., Ltd.	lithography system for high PPI	
				LCD manufacturing	
				Demagnification imaging	
	19.25 19.40	Bin HU	Beijing Institute of	improved by mask in a	
	18:25-18:40	ын по	Technology	hyperlens photolithography	
				system	



June 28 Conference 5: Meta Surface-wave and Surface Plasmon Lithography ChengHua hall, floor 5

Date	Time	Name	Organization	Title	Remark
	08:30-09:00	Jinghua TENG	Institute of Materials Research and Engineering	Optical wavefront control by photon sieves	Invited
	09:00-09:30	Qiwen ZHAN	University of Shanghai for Science and Technology	Magnified photonic spin-Hall effect and applications	Invited
	09:30-10:00	Xueqian ZHANG	TianjinUniversity	Terahertz wavefront control based on dielectric metasurface	Invited
	10:00-10:15			Tea Time	
	10:15-10:45	Shaoqiu XIAO	University of Electronic Science and Technology of China	Index-modulated sub-wavelength patches for antenna performance improvement	Invited
	10:45-11:15	Kai CHEN	Jinan University	Scalable aluminum metamaterial perfect absorber by colloidal lithography	Invited
June28	11:15-11:30	Jiao JIAO	University of Electronic Science and Technology of China	Design of nano superlens capable of dynamic manipulative focal length	
	11:30-11:45	Fen ZHAO	Chongqing University	A broadband metasurface device with reduced chromatic dispersion	
	11:45-12:00	Yuyan LI	Chongqing University	Reflective quarter-wave plate based on cross-shaped nano-antenna	
	12:00-13:00			Lunch	
	13:00-13:15	Yifeng XIANG	University of Science and Technology of China	Manipulating the plasmonic modes of silver nanowire with a photonic band gap structure	
	13:15-13:30	Xing LI	Shandong NormalUniversity	An experimental solution for the plasmonic and photonic mode waves launched by metal nano-slits	
	13:30-13:45	Ying XIANG	Guangdong University of Technology	液晶中微观结构的形成和调控	
	13:45-14:15	Yiping	Shenzhen University	Femtosecond-laser-inscribed	Invited

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		WANG		fiber Bragg gratings and applications	
	14:15-14:45	Fei XU	Nanjing University	Second harmonic generation in optical microfibers	Invited
	14:45-15:15	Baicheng YAO	University of Electronic Science and Technology of China	Gate-tunable frequency combs in graphene-nitride microresonators	Invited
	15:15-15:45	Weihong BI	Yanshan University	Preparation and application of superimposed photonic crystal fiber gratings	Invited
	15:45-16:00			Tea Time	
	16:00-16:30	Yikun LIU	Sun Yat-sen University	Ultrafast light field manipulation using cholesteric liquid crystals	Invited
June	16:30-17:00	Wei HU	Nanjing University	Optically addressed liquid spatial light modulator	Invited
28	17:00-17:15	Hongru GUO	University of Electronic Science and Technology of China	Research review on the development of liquid crystal optical phased array device on the application of free space laser communication	
	17:15-17:30	Ting CHEN	Wuhan Polytechnic University	Study on the low temperature dependence of viscosity for high-birefringence liquid crystals used in high frequency	
	17:30-17:45	Xiaoxiao WU	Xiamen Tianma Microelectronics Co., Ltd.	High resolution LCD technology for VR	
	17:45-18:00	Yize ZHAO	University of Electronic Science and Technology of China	A voltage tunable metasurfaces as phase shifter at U-band based on liquid crystal	
	18:00-18:30	Ruiqi DUAN	Sichuan University	Local surface plasmon resonance biosensor and its medical applications	Invited



Conference 7: Innovative Manufacturing Technology

The theme of this conference is mainly about the innovative manufacturing technology, including biological manufacturing, multi-scale manufacturing, flexible manufacturing, intelligent manufacturing, bionic manufacturing, virtual fusion manufacturing and green manufacturing. The goal of this topic is to bring together leading academic scientists, researchers and research scholars to exchange and share their experiences and research results on all aspects of innovative manufacturing technologies. It also provides a premier interdisciplinary platform for researchers, practitioners and educators to present and discuss the most recent innovations, trends, and concerns as well as practical challenges encountered and solutions adopted in the fields of innovative and disruptive manufacturing technologies.

- Biological manufacturing
- Multi-scale manufacturing
- Flexible manufacturing
- Intelligent manufacturing
- Bionic manufacturing
- Virtual fusion manufacturing
- Green manufacturing

Conference Chairs:

Xingjiang Liu, China Electronics Technology Group CorporationXiaodong He, Harbin Institute of TechnologyRui Zhou, Xiamen University



June 27 Conference 7: Innovative Manufacturing Technology QingBaiJiang hall, floor 5

Date	Time	Name	Organization	Title	Remark
	08:30-09:00	Genquan HAN	Xidian University	Negative capacitance transistors with sub-kT/q swing	Invited
	09:00-09:30	Yaoyu CAO	Jinan University	Super-resolution direct laser writing and its application in nanofabrication	Invited
			University of	Integration of controllable	Invited
	00 20 10 00	ъ ми	Science and	microstructures inside a microfluidic	
	09:30-10:00	Dong WU	Technology of	chip by direct femtosecond laser	
			China	writing	
	10:00-10:15		,	Tea Time	
			77'I T'	Template to induce self-assembly	
	10:15-10:45	Hongzhong LIU	Xi'an Jiaotong University	technology and application in biomimicry	Invited
	10:45-11:15	Yunfeng PENG	Xiamen University	Investigation on the nonlinear relationship between relative velocity and material removal in bonnet polishing	Invited
June	11:15-11:45	Dongjiang WU	Dalian University of Technology	Wear mechanism of Al ₂ O ₃ -ZrO ₂ eutectic ceramic via ultrasonic-assisted laser engineered net shaping (LENS)	Invited
27	11:45-14:00			Lunch	
	14:00-14:30	Lingfei JI	Beijing University	Structural modifications induced by	Invited
			of Technology	ultrafast IR laser pulses in sapphire	
	14:30-15:00	Xiaohui LI	Shaanxi Normal University	Ultrafast pulse based on few-layer	Invited
				Bismuthene via evanescent field	
				interaction	
	15:00-15:30	1-15:30 Feng XU	Xi'an Jiaotong	Micro- and nano-technologies for	Invited
			University	point-of-care diagnostics	invited
	15:30-15:45		,	Tea Time	
	15:45-16:00	Haiming XU	Ningxia University	Research on hand-eye calibration method based on stereo vision for harvesting robot	
	16.00 16.15	5 Xiaojie LI	Hunan University	Fabrication of superhydrophobic	
	16:00-16:15			magnesium surface with durability	
	16:15-16:30	Yitao LU	Huazhong University of Science and	Ge ₂ Sb ₂ Te ₅ all-optical switch	
			Technology		
	16:30-16:45	Wang PENG	Xiamen University	Effect of process parameters on laser micromilling of SiC microchannels	



Conference 8: Flexible Materials and Devices

Recent progresses in materials development, device engineering and mechanical design have given birth to photonic materials, devices and systems with unconventional functionalities such as mechanical flexibility, biocompatibility and resorbability. These novel features facilitate the integration of photonic and electronic devices with soft, elastic and/or curved substrates for various biomedical applications. Innovative material design and device architectures are being actively pursued to address the challenges associated with the multifunctional integration of organic/inorganic photonic components with various biological systems. Latest scientific and technical advances have broadened the palette of materials which spans from organic polymers to semiconductors, metals, ceramics, glasses, and hybrid materials across different structural hierarchies and length scales. Innovative processing and assembly, based on a clever combination of these new materials, have enabled a wide spectrum of optoelectronic devices like waveguides, LEDs, photodetectors and lasers to be integrated onto wearable and implantable platforms by leveraging non-classical fabrication methods include advanced 3D manufacturing, transfer printing, nanolithography and self-assembly. These bio-integrated systems open up emerging application venues include but are not limited to epidermal sensors, optogenetic probes, and implantable transient devices. This symposium provides a forum to discuss various approaches to realize advanced high performance flexible photonic materials, devices and systems. It will focus on functional material design, characterization and their applications in photonic devices for wearable and The presentations bio-implantable applications. and invited talks interdisciplinary fields including materials science, physics, chemistry, biology, mechanical engineering and electrical engineering.

- Flexible, stretchable and curved optoelectronic devices and systems
- Wearable devices
- Implantable devices
- Degradable devices
- Bio-inspired and bio-mimetic devices
- Optical neural interfaces
- Optoelectronic devices for biomedical system



Conference Chairs:

Wei Huang, Northwestern Polytechnical University

Yonggang Huang, Northwestern University (USA)

Xue Feng, Tsinghua University

June 27 Conference 8: Flexible Materials and Devices XinDu hall, floor 5

Date	Time	Name	Organization	Title	Remark	
	8:30-9:00	Yanlin SONG	Institute of Chemistry Chinese Academy of Sciences	Green printing for functional devices by droplet manipulation	Invited	
	9:00-9:30	Yongfeng MEI	Fudan University	Rolled-up nanomembranes: from fabrication to applications	Invited	
	9:30-10:00	Caofeng PAN	Beijing Institute of Nanoenergy and Nanosystems, Chinese Academy of Sciences	基于压电光电子学效应的 ZnO 纳 米线阵列应力传感与成像系统研 究	Invited	
	10:00-10:15	Fengyu LI	Institute of Chemistry Chinese Academy of Sciences	Printed droplet manipulation for flexible multi-analysis electronics		
	10:15-10:45			Tea Time		
	10:45-11:15	Jianpu WANG	Nanjing Tech University	High performance perovskite light-emitting diodes	Invited	
June 27	11:15-11:45	Xing SHENG	Tsinghua University	Implantable optoelectronic devices for deep-brain neural modulation and sensing	Invited	
	11:45-12:00	Qingxin TANG	Northeast Normal University	Conformal organic field-effect transistor array fabricated by photo-lithography		
	12:00-14:00			Lunch		
	14:00-14:30	Guozhen SHEN	Institute of Semiconductors, CAS	One-dimensional semiconducting nanostructures for flexible image sensors	Invited	
	14:30-15:00	Ruiwei LI	Ningbo Institute of Industrial Technology, CAS	Flexible tactile sensor with digital output for E-skin	Invited	
	15:00-15:15	Meng SU	Institute of Chemistry Chinese Academy of Sciences	Self-assembling of nanomaterials via droplet manipulation for multifunctional electronics		

	15:15-15:45	Tea Time				
June	15:45-16:15	Weihua PEI	Institute of Semiconductors Chinese Academy of Sciences	Hybride-integrated flexible electrode on Sapphire-based µLED optoelectrodes for high-spatiotemporal-accuracy optogenetic studies	Invited	
27	16:15-16:45	Shih-Chi CHEN	Chinese University of Hong Kong	Ultra-precise roll-to-roll machine for fabricating next-generation flexible electronic devices	Invited	
	16:45-17:15	Ni ZHAO	The Chinese University of Hong Kong	Solution-Processed Energy Devices and Sensors	Invited	
	17:15-17:30	Miao YU	University of Electronic Science and technology of china	Enhancing the wettability of PEDOT:PSS layer with plasma treatment method in perovskite solar cells		

June 28 Conference 8: Flexible Materials and Devices XinDu hall, floor 5

Date	Time	Name	Organization	Title	Remark	
	08:30-09:00	Xue FENG	Tsinghua University	类皮肤柔性生物器件	Invited	
	09:00-9:30	Yuan LIN	University of Electronic Science and Technology of China	Stretchable and flexible sensors based on oxide thin films	Invited	
	09:30-10:00	Youfan HU	Peking University	High-performance flexible electronics based on carbon nanotubes	Invited	
June 28	10:00-10:30	Yaping DAN	Shanghai Jiao Tong University	Dynamics of charge carriers in silicon nanowire photoconductors revealed by photo Hall effect measurements	Invited	
	10:30-10:45	Tea Time				
June	10:45-11:15	Xian HUANG	TianjinUniversity	High-throughput implantable flexible electronics devices	Invited	
28	11:15-11:45	Jingquan LIU	Shanghai Jiao Tong University	Flexible MEMS neural interface devices	Invited	
	11:45-12:00	Haochen LI	Nanjing University of Science and Technology	A novel flexible wireless pressure sensor for diagnosis of the osteofascial compartment syndrome		



Conference 9:Optoelectronic Materials and Devices for Sensing and Imaging

This conference chapter refers to the study of optoelectronic materials and devices for sensing and imaging, including properties of optoelectronic materials, data acquisition and analysis of detector, image processing, new display technology, thin film transistor technology and organic and polymer storage equipment. The research objection of this conference is to design and manufacture devices for sensing and imaging with various optoelectronic materials, which could provide physical platform and technical support for the next generation of display technology. The goal of this chapter is to exchange recent development and breakthrough in the optoelectronic materials and devices for sensing and imaging, including properties of optoelectronic materials, the device design and fabrication, the novel application. This conference chapter mainly includes eleven session parts:

- Properties of optoelectronic materials
- Nanomaterials used in optoelectronic equipment
- Properties of imaging acceptance material
- Detector design, assembly and fusion
- Data acquisition and analysis of detector
- Image processing
- New display technology
- Organic and polymer light emitting devices for display and lighting
- Related technologies of LED and OLED
- Thin film transistor technology
- Organic and polymer storage equipment

Conference Chairs:

Yadong Jiang, Dean of School of Optoelectronic Information, University of Electronic Science and Technology of China

Bernard Kippelen, Vice Director, Center of Organic Photonics and Electronics, Georgia Institute of Technology (USA)

Junsheng Yu, State Key Laboratory of Electronic Thin Films and Integrated Devices



June 28 Conference 9:Optoelectronic Materials and Devices for Sensing and Imaging

QingYang hall, floor 5

Time	Name	Organization	Title	Remark		
08:00-08:30	Lu LI	Chongqing University	Flexible solar cell via ultrasonic	Invited		
		-				
08:30-09:00	Zhenming PENG			Invited		
00.50 07.00			_			
		China				
		Taiyuan University of				
09:00-09:30	Hua WANG	Technology		Invited		

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09:30-10:00	Jiang HUANG			Invited		
			method			
	Lingma SUN	•	A fast Lung segmentation method on CT image using a morphological analysis			
10:00-10:15						
10:15-10:30	Yuhan LIU	-	Connected component-based river detection using ULBP feature in infrared image			
10.20 10.40						
10.30-10.40			T			
10:40-10:55	10:55 Xifa SONG					
		1				
10.55-11.10	Yuevin I AN		_			
10.55-11.10	Auexiii LAN					
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11:10-11:25	Yifeng XIONG	Naniing University				
11.10-11.23		realigning Onliversity	_			
		Shanghai Institute of	F	 		
11:25-11:40	Ran TAO		An overview on theory and			
		-	algorithm of light field imaging			
		_	technology			
			A new blind-pixel detection			
11:40-11:55	11:40-11:55 Wenxiu W	Wenxiu WANG	Technical Physics of	method for 384×288 long-wave		
	08:00-08:30 08:30-09:00 09:00-09:30 10:00-10:15 10:15-10:30 10:30-10:40 10:40-10:55 11:10-11:25	08:00-08:30 Lu LI 08:30-09:00 Zhenming PENG 09:00-09:30 Hua WANG 10:30-10:00 Jiang HUANG 10:15-10:30 Yuhan LIU 10:30-10:40 Xifa SONG 10:55-11:10 Xuexin LAN 11:10-11:25 Yifeng XIONG 11:25-11:40 Ran TAO	08:00-08:30 Lu LI Chongqing University of Arts and Sciences 08:30-09:00 Zhenming PENG University of Electronic Science and Technology of China 09:00-09:30 Hua WANG Taiyuan University of Technology 09:30-10:00 Jiang HUANG Electronic Science and Technology of China 10:00-10:15 Lingma SUN University of Electronic Science and Technology of China 10:15-10:30 Yuhan LIU University of Electronic Science and Technology of China 10:30-10:40 Tea Research Institute of Highway Ministry of Transport 10:40-10:55 Xifa SONG Highway Ministry of Transport 11:10-11:25 Yifeng XIONG Nanjing University 11:25-11:40 Ran TAO Shanghai Institute of Technical Physics of the Chinese Academy of Sciences 11:40-11:55 Wenxiu WANG Shanghai Institute of	O8:00-08:30 Lu Li Chongqing University of Arts and Sciences Study on rapid sensitivity of infrared radiation for the limb atmosphere based on the transport theory		

COL	nerenc	e Progra	Ш	OMATI			
			the Chinese Academy	infrared focal plane arrays			
			of Sciences	images			
	11:55-13:00		Lu	nch			
				Synthesis and characterization			
	12 00 12 20	71. 7110	Cl. TI.	of perovskite CsPbBr ₃	T 1		
	13:00-13:30	Zhigang ZANG	Chongqing University	nanomaterials and their	Invited		
				optoelectronic applications			
				Wide bandgap donor and			
	13:30-14:00	Qiang PENG	Sichuan University	acceptor materials for	Invited		
				nonfullerene organic solar cells			
			University of				
June			Electronic Science	Optoelectronic devices based on			
28	14:30-15:00	Shibin LI	and Technology of	halide perovskite	Invited		
			China	semiconductors			
			Shanghai Institute of	10 1 2 7077			
		Yanping	Technical Physics,	A self-adaptive ROIC for long			
	15:00-15:15	ZHONG	Chinese Academy of	wavelength photoconductive			
			Sciences	infrared detector			
				X-ray detector with high			
	15:15-15:30	Houzhi CAI	Shenzhen University	temporal resolution by using			
				pulse-dilation technology			
	15:30-15:40	Tea Time					
				Automatic detection system for			
	15:40-15:55	Shengnan SUN	Northeast Normal University	spring hooks on car seat back			
				based on feature detection and			
				line segment			
		6:10 Wenwei SONG	Southwest Jiaotong University	Weak image edge detection			
	15:55-16:10			based on improved fuzzy			
				inference			
				The signal processing system of			
			Nanjing University of	a differential capacitive			
	16:10-16:25	Wusen LI	Science and	micro-displacement sensor for			
			Technology	the controlling of segmented			
				mirror			
			University of	Missing pins detection of power			
	16:25-16:40	Bingxin HUAI	Electronic Science	equipment firmware based on			
	10.23-10.40	Biligxiii HOAI	and Technology of	UAV image under complex			
			China	environment			
			Shanghai Institute of	Design of mid-infrared (8-12			
			Technical Physics of	μm) absorption structures for			
	16:40-16:55	Wei ZHOU	the Chinese Academy	Mn-based oxides thin film			
			of Sciences	detectors			
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June 28	16:55-17:10	Rui PAN	University of Electronic Science and Technology of China	Ultra-highly responsivity graphene-CuInS ₂ QDs hybrid photodetector
	17:10-17:25	Ning LEI	Beijing Institute of Space Mechanics and Electricity	A research on real-time non-uniformity correction and blind pixels auto-searching and compensation for IRFPA based on FPGA
	17:25-17:40	Weiwei MENG	University of Electronic Science and Technology of China	A multi-band terahertz metamaterial absorber with novel structure
	17:40-17:55	Dong WANG	Beijing Institute of Space Mechanics and Electricity	The timing analysis of double sampling technique with different pixel structure for area array CMOS image sensors